

Digital Integrated Circuit

Lecture 7 MOS Transistor Theory

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Review of Previous Lecture

Lecture 6

- Long-channel IV
 - Input and output characteristics
- Capacitance
 - Area and perimeter dependence of diffusion capacitance
- Nonideal IV
 - ON current and OFF current
 - Various device options

2.4 Nonideal IV

2.4. Nonideal IV (4)

- Intel 22 nm transistor

Table I. 22nm modular SoC transistor options and device characteristics

Transistor Type	High Speed Logic		Low Power Logic		High Voltage	
Options	High Performance (HP)	Standard Perf./ Power (SP)	Low Power (LP)	Ultra Low Power (ULP)	1.8 V	3.3 V
Vdd (Volt)	0.75 / 1	0.75 / 1	0.75 / 1	0.75/1.2	1.5/1.8/3.3	3.3 / >5
Gate Pitch (nm)	90	90	90	108	min. 180	min. 450
Lgate (nm)	30	34	34	40	min. 80	min. 280
N/PMOS Idsat/loff (mA/um)	1.08/ 0.91 @ 0.75 V, 100 nA/um	0.71 / 0.59 @ 0.75 V, 1 nA/um	0.41 / 0.37 @ 0.75 V 30 pA/um	0.35 / 0.33 @ 0.75 V 15 pA/um	0.92 / 0.8 @ 1.8 V 10 pA/um	1.0 / 0.85 @ 3.3 V 10 pA/um

(Intel's 2012
IEDM abstract)

2.4. Nonideal IV (5)

- Mobility degradation due to the vertical E-field
 - Collisions with oxide interface

$$\mu_{\text{eff}-n} = \frac{540 \frac{\text{cm}^2}{\text{V} \cdot \text{s}}}{1 + \left(\frac{V_{gs} + V_t}{0.54 \frac{\text{V}}{\text{nm}} t_{\text{ox}}} \right)^{1.85}}$$

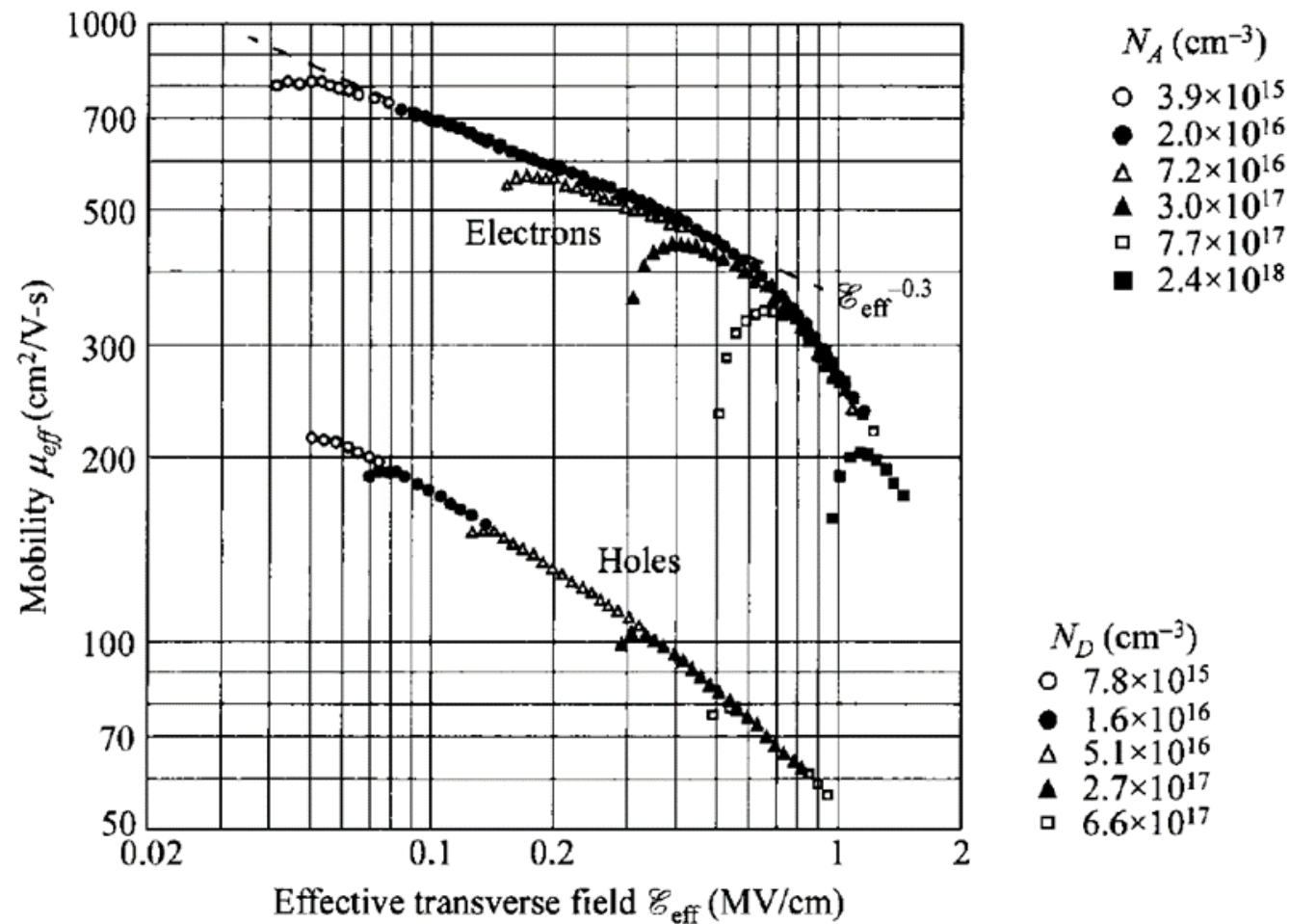
$$\mu_{\text{eff}-p} = \frac{185 \frac{\text{cm}^2}{\text{V} \cdot \text{s}}}{1 + \frac{|V_{gs} + 1.5V_t|}{0.338 \frac{\text{V}}{\text{nm}} t_{\text{ox}}}}$$

Calculate the mobilities at $|V_{gs}| = 1.0 \text{ V}$. Assume that $t_{\text{ox}} = 1.05 \text{ nm}$ and $|V_t| = 0.3 \text{ V}$.

- Why do we have different behaviors for electrons and holes?

2.4. Nonideal IV (6)

- Experimental data (“Universal” mobility curve)



Inversion layer
mobility (Sze's book)

2.4. Nonideal IV (7)

- Velocity saturation
 - Saturation velocity (Canali model)
 - Electrons: 1.07×10^7 cm/sec
 - Holes: 8.37×10^6 cm/sec
 - A simple model

$$v = \begin{cases} \frac{\mu_{\text{eff}} E}{1 + \frac{E}{E_c}} & E < E_c \\ v_{\text{sat}} & E \geq E_c \end{cases}$$

$$E_c = \frac{2v_{\text{sat}}}{\mu_{\text{eff}}}$$

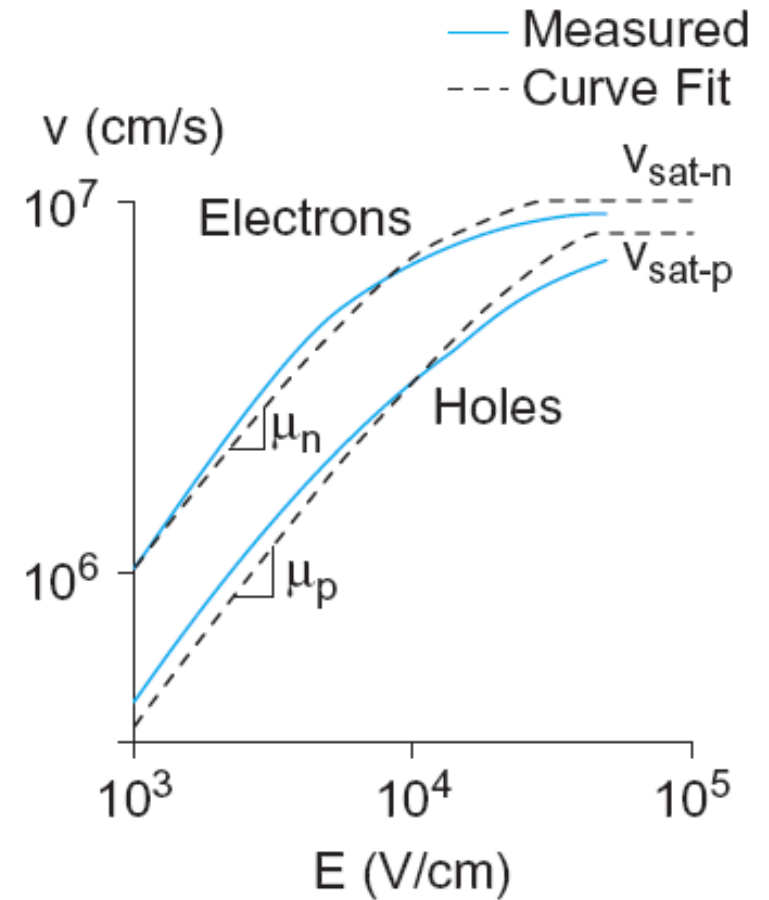


Fig. 2.15

2.4. Nonideal IV (8)

- When the electric field is lower than E_c ,

$$E = \frac{I_d}{\mu_n C_{OX} W (V_g - V_t - V_c) - \frac{I_d}{E_c}} = \frac{dV_c}{dx}$$

- (Note that the sign is not correct but understood.)
- Then, the integration gives

$$\begin{aligned} LI_d &= \int_{V_s}^{V_d} \left[\mu_n C_{OX} W (V_g - V_t - V_c) - \frac{I_d}{E_c} \right] dV_c \\ &= \mu_n C_{OX} W \left[(V_g - V_t) V_{ds} - \frac{1}{2} V_{ds}^2 \right] - \frac{I_d}{E_c} V_{ds} \end{aligned}$$

2.4. Nonideal IV (9)

- Drain current with the velocity saturation

$$I_d = \frac{1}{L + \frac{V_{ds}}{E_c}} \mu_n C_{OX} W \left[(V_g - V_t) V_{ds} - \frac{1}{2} V_{ds}^2 \right]$$

– With $V_c = E_c L$,

$$I_d = \frac{1}{1 + \frac{V_{ds}}{V_c}} \mu_n C_{OX} \frac{W}{L} \left[(V_g - V_t) V_{ds} - \frac{1}{2} V_{ds}^2 \right]$$

– The factor, $\frac{1}{1 + \frac{V_{ds}}{V_c}}$, describes the velocity saturation.

– Then, when do we have the saturation?

2.4. Nonideal IV (10)

- Condition for saturation, $E = E_c @ x = L$
 - In this case, $V_d = V_{dsat}$ and $I_d = I_{dsat}$

$$E_c = \frac{I_{dsat}}{\mu_n C_{OX} W (V_g - V_t - V_{dsat}) - \frac{I_{dsat}}{E_c}}$$

- The saturation current becomes

$$I_{dsat} = \frac{1}{2} \mu_n C_{OX} W (V_g - V_t - V_{dsat}) E_c$$

- What is V_{dsat} ?

2.4. Nonideal IV (11)

- Equating two expressions,

$$I_{dsat} = \frac{1}{2} \mu_n C_{OX} W (V_g - V_t - V_{dsat}) E_c$$
$$I_{dsat} = \frac{1}{1 + \frac{V_{dsat}}{V_c}} \mu_n C_{OX} \frac{W}{L} \left[(V_g - V_t) V_{dsat} - \frac{1}{2} V_{dsat}^2 \right]$$

- With the gate overdrive voltage, $V_{GT} \equiv V_g - V_t$, we can find

$$V_{dsat} = \frac{V_{GT} V_c}{V_{GT} + V_c}$$
$$I_{dsat} = C_{OX} W \frac{V_{GT}^2}{V_{GT} + V_c} v_{sat}$$

- Two extreme cases, $V_{GT} \ll V_c$ and $V_{GT} \gg V_c$

Homework#2

- Due: AM08:00, September 21
- Problem#1
 - Compare three modes for the velocity saturation:
 - 1) The one studied in this lecture.
 - 2)
$$v_{sat} = \frac{\mu_{eff} E}{\sqrt{1 + \left(\frac{E}{E_c}\right)^2}}$$
 - 3)
$$v_{sat} = \frac{\mu_{eff} E}{1 + \frac{E}{E_c}}$$
 for any E value
 - Draw the velocity-field graph in the semi-logarithmic scale. μ_{eff} is 710 cm²/V sec and E_c is 11 kV/cm. The electric field varies from 100 V/cm to 100 kV/cm.

Homework#2

- Problem#2

- Draw the output characteristics of an NMOSFET, by using two IV models. Compare them.
- 1) Long-channel IV
- 2) The one studied in this lecture.
- Parameters are: W is 100 μm . L is 1 μm . t_{ox} is 25 nm. The effective mobility is assumed to be a constant of 500 $\text{cm}^2/\text{V sec}$, for simplicity. E_c is 11 kV/cm. Consider five values of V_{GT} : 0.5 V, 1.0 V, 1.5 V, 2.0 V, and 2.5 V. Increase the drain voltage up to 3.0 V.

2.4. Nonideal IV (12)

- Threshold voltage (Body effect)

- It is given by

$$V_t = \frac{\sqrt{2\epsilon_{si}qN_A}}{C_{ox}} \sqrt{\phi_s + V_{sb}} + V_{FB} + \phi_s$$

$$\phi_s = 2v_T \log \frac{N_A}{n_i}$$

- At zero V_{sb} ,

$$V_{t0} = \gamma \sqrt{\phi_s + V_{sb}} + V_{FB} + \phi_s$$

- Therefore,

$$V_t = V_{t0} + \gamma (\sqrt{\phi_s + V_{sb}} - \sqrt{\phi_s})$$

2.4. Nonideal IV (13)

- Leakage
 - Subthreshold slope
 - Drain-induced barrier lowering
 - Gate-induced drain leakage

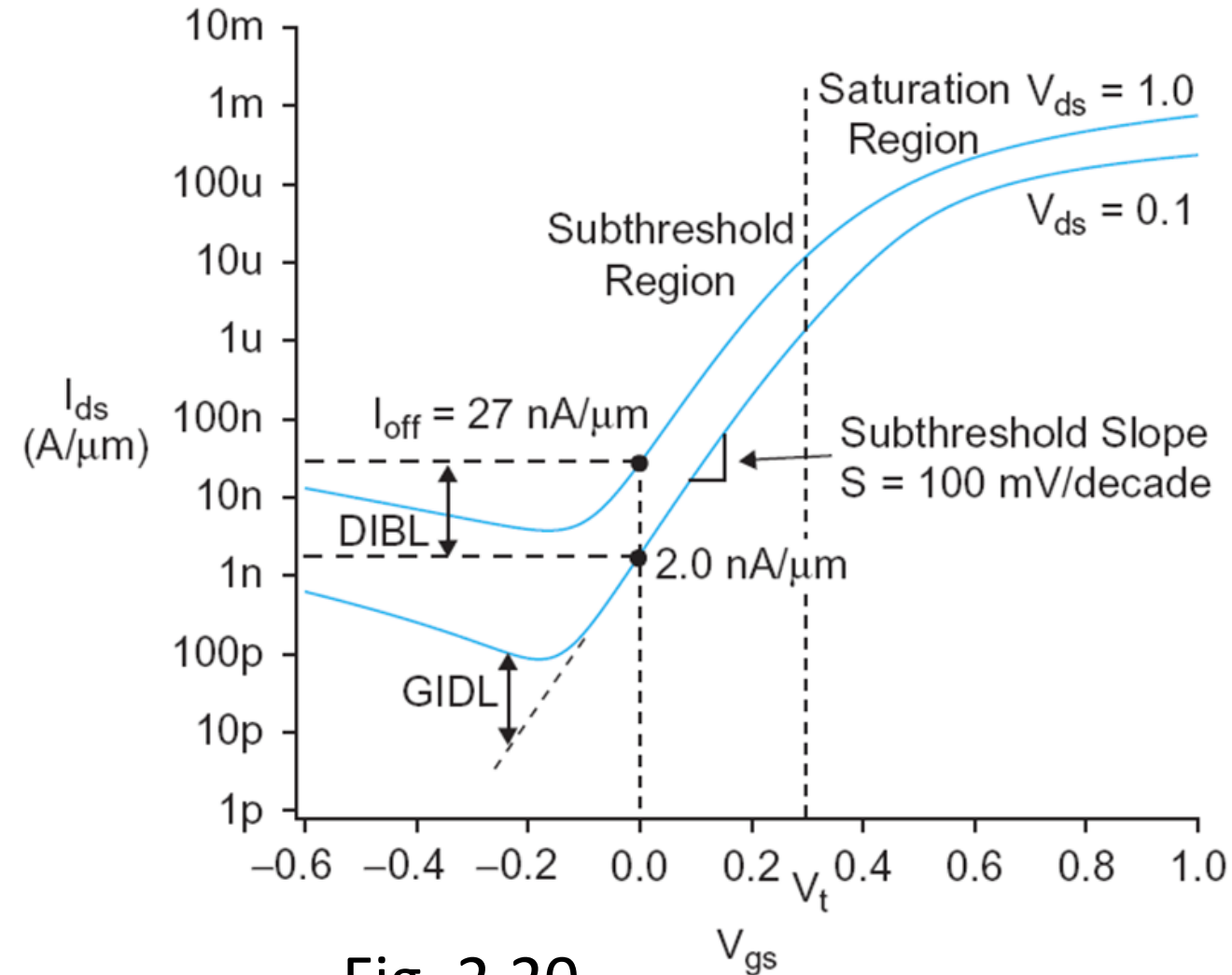


Fig. 2.20

Thank you!